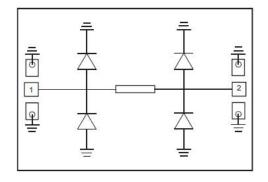


GaAs MMIC Limiter Chip, DC-18GHz

Performance characteristics

- Frequency range: DC 18 GHz
- Insertion loss : 0.2 dB (Typ.)
- Clipping level: 19dBm
- Power handling: 33dBm (CW)
- 500hm input / output
- 100% on-wafer testing
- Chip size: 1.4 x 0.62 x 0.1mm

Functional Block Diagram



Product Introduction

GLM-0018E is a GaAs MMIC limiter with a frequency range of DC~18GHz , 50Ω input/output , less than 0.2dB within the operating frequency band , 1.2 input/output standing wave , and 2W burnout resistance. The chip is small in size and does not integrate DC isolation capacitors at the input/output. The chip uses on-chip through-hole metallization technology to ensure good grounding, does not require additional grounding measures, and is simple and convenient to use. The back of the chip is metallized and is suitable for eutectic sintering or conductive adhesive bonding processes.

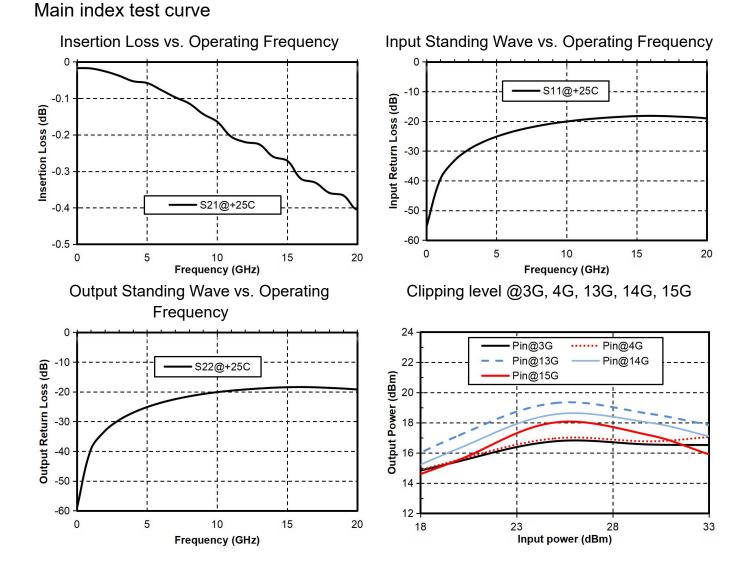
Use restriction parameter ¹		
Maximum input power	+33dBm	
Operating temperature	-55 ~ + 125 °C	
Storage temperature	-65 ~ +150°C	

[1] Exceeding any of these maximum limits may cause permanent damage.

Electrical performance parameters (TA = +25°C)					
Index	Minimum	Typical Value	Maximum	Unit	
Frequency Range	DC-18			GHz	
Insertion loss	-	0.2	0.4	dB	
Input return loss	18	24		dB	
Output return loss	18	19		dB	
Limiting level@Pin=30dBm	-	19	-	dBm	
Anti-burning power		33		dBm	



GaAs MMIC Limiter Chip, DC - 18 GHz



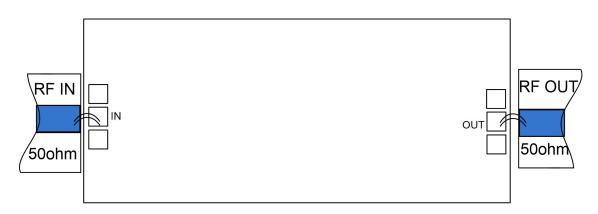
Appearance structure ²





[2] All units in the figure are micrometers

Recommended assembly drawing



Bonding point definition			
Bonding point	Function	Functional Description	
number	Symbol		
1 RF COMM		RF signal input terminal , it is recommended to connect an	
		external DC blocking capacitor	
2 RF OUTPUT		RF signal output terminal , it is recommended to connect an	
	external DC blocking capacitor		
Chip bottom	GND	The bottom of the chip needs to be well grounded to RF and	
		DC	

Precautions for use

- The chip needs to be stored in an anti-static container and kept in a nitrogen environment.
- Do not attempt to clean the bare die surface using wet chemical methods.
- Please strictly comply with ESD protection requirements to avoid electrostatic damage to bare chips.

Standard Circuit

- General operation: Please use precision pointed tweezers to pick up bare chips. Avoid touching the chip surface with tools or fingers during operation.
- Rack mounting operation suggestions: Bare chip mounting can be done by AuSn solder eutectic sintering or conductive adhesive bonding. The mounting surface must be clean and flat.
- Sintering process: It is recommended to use AuSn solder sheets with a gold-tin ratio of 80/20. The working surface temperature reaches 255 °C and the tool (vacuum chuck) temperature reaches 265 °C. When the high-temperature mixed gas (nitrogen-hydrogen ratio of 90/10) is blown to the chip, the temperature at the top of the tool should be raised to 290 °C. Do not let the chip exceed 320 °C for more than 20 seconds. The friction time should not exceed 3 seconds.
- Bonding process: The amount of conductive glue dispensed should be as small as possible. After the chip is placed in the installation position, the conductive glue should be vaguely visible around it . For curing conditions, please follow the information provided by the conductive glue manufacturer.
- Bonding operation suggestions: Use Φ0.025mm (1mil) gold wire for both ball and wedge bonding. Thermo-ultrasonic bonding temperature is 150 °C. The pressure of the wedge for ball bonding is 40~50gf, and the pressure of the wedge bonding is 18~22gf. Use the smallest possible ultrasonic energy. The bonding starts at the pressure point on the chip and ends at the package (or substrate).